## **Electronic Supplementary Information (ESI)**

## Toward Efficient Solid-State p-Type Dye-Sensitized Solar Cells: The Dye Matters

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Table S1. Photovoltaic parameters of solid-state p-type DSSC based on PCBM and on the DPP-PYRO dye, with different concentration of CDCA treatment (spincoating CDCA solution of on the sensitized samples, no rinsing before PCBM coating). The treatment is intended to assist the coverage of NiO after dye-loading to prevent NiO surface being exposed to PCBM causing recombination. The solar cells were placed under standard solar illumination at 100 mW cm<sup>-2</sup> and AM1.5G spectral distribution. NiO film thickness is 0.65  $\mu$ m.

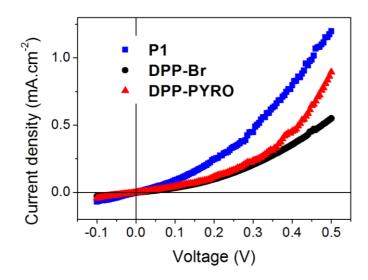
<b>CDCA concentration</b>	V <sub>oc</sub> (mV)	J <sub>sc</sub> (mA.cm <sup>-2</sup> )	FF	η (%)
0	119	0.05	0.26	0.001
2mM	189	0.11	0.28	0.006
5mM	187	0.09	0.29	0.005
10mM	237	0.27	0.27	0.017
20mM	260	< 0.01	0.25	< 0.001

**Table S2**. Photovoltaic parameters of solid-state p-type DSSC based on **PCBM** and on **DPP-PYRO** and **DPP-Br** dyes, as a function of porous NiO layer thickness. The solar cells were placed under standard solar illumination at 100 mW cm<sup>-2</sup> and AM1.5G spectral distribution.

Dye	Thickness of porous NiO (µm)	V <sub>oc</sub> (mV)	J <sub>SC</sub> (mA cm <sup>-2</sup> )	FF	η (%)
	0.65	228	0.32	0.32	0.023
<b>DPP-PYRO</b>	1.5	182	0.07	0.30	0.004
	1.7	127	0.13	0.25	0.004
DPP-Br	0.65	198	0.45	0.32	0.028
	1.5	116	0.10	0.29	0.003
	1.7	96	0.03	0.25	0.001
No dye	0.65	3	< 0.01	0.25	< 0.001

**Table S3**. Fitting parameters used to adjust the experimental PL decay traces with biexponential decay functions, for the three dyes grafted on  $Al_2O_3$ , without and in the presence of **PCBM**.

		$a_1$	$ au_1$	$a_2$	$ au_2$
		(arb. units)	(ps)	(arb. units)	(ps)
P1	No PCBM	0.014	433	0.0031	1408
	With PCBM	0.015	337	0.0034	1205
DPP-Br	No PCBM	0.021	841	0.0092	3634
	With PCBM	0.051	253	0.0064	1694
DPP-PYRO	No PCBM	0.020	281	0.0016	1578
	With PCBM	0.042	100	0.0018	961



**Figure S1**. Current density – voltage characteristics in the dark of solid-state p-type DSSC based on **PCBM** and on **DPP-PYRO** (red triangles), **DPP-Br** (blue circles), and **P1** (black squares) dyes.

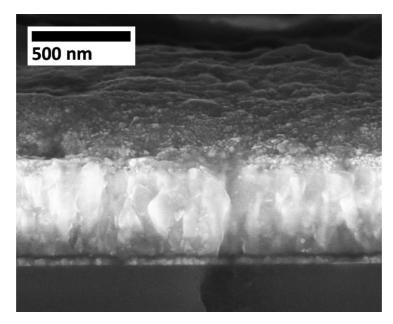
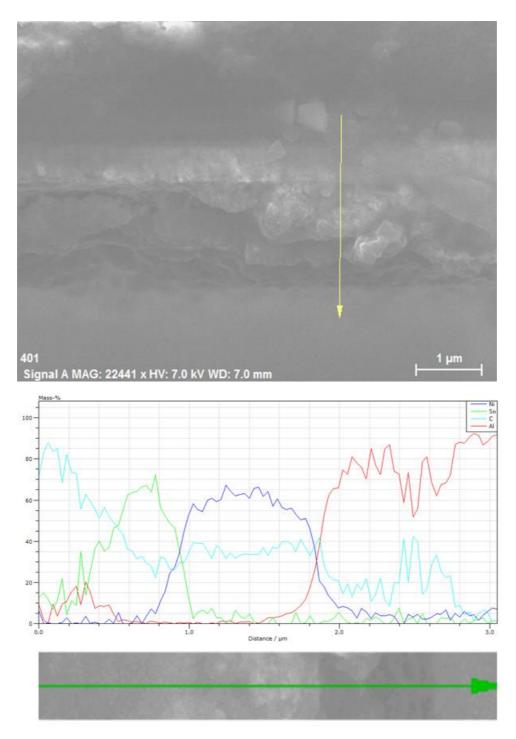
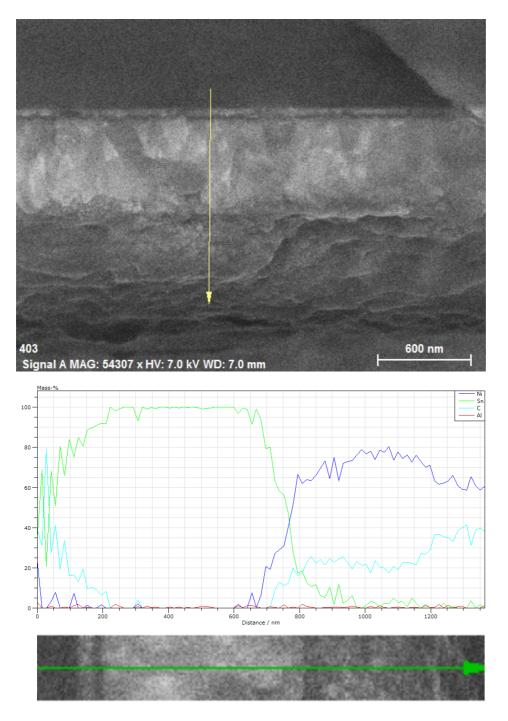


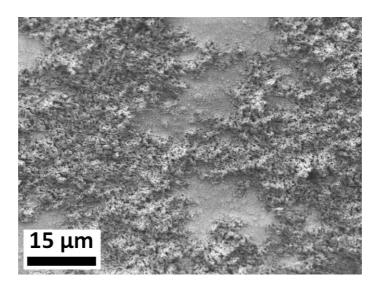
Figure S2. SEM cross-section of sample FTO/dense NiO/Porous NiO/DPP-Br/PCBM.



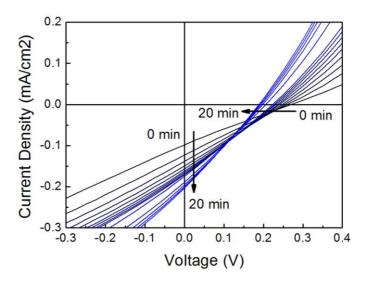
**Figure S3**. SEM image and corresponding EDX profiles for Ni, Sn, and C, for sample FTO/dense NiO/Porous NiO/**P1**/PCBM.



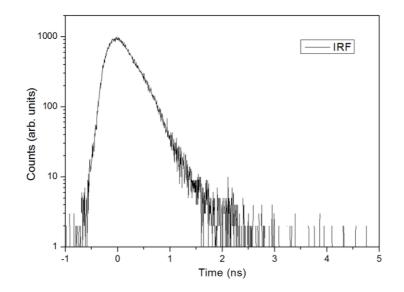
**Figure S4**. SEM image and corresponding EDX profiles for Ni, Sn, and C, for sample FTO/dense NiO/Porous NiO/**DPP-Br**/PCBM.



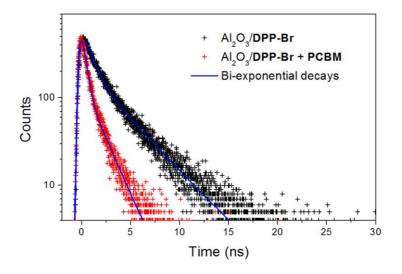
**Figure S5**. Top SEM image of sample FTO/dense NiO/Porous NiO/**DPP-PYRO**/PCBM showing a strong aggregation of **PCBM** on top of the device stacking.



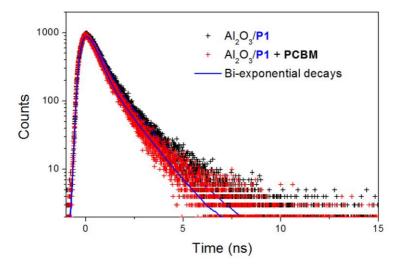
**Figure S6**. Electrical characteristics of solid-state p-type DSSC based on dye **P1** and **PCBM**, as a function of illumination time at 100 mW cm<sup>-2</sup> (AM1.5G). The measurements were made under inert atmosphere in a glovebox.



**Figure S7**. Instrument Response Function (IRF) of the apparatus used for the measurement of photoluminescence decays (Edinburgh Instrument FLS 980).



**Figure S8**. Time-resolved photoluminescence traces for system based on dye **DPP-Br** grafted on  $Al_2O_3$ , without (black data) and in the presence of **PCBM** (red data). The excitation is performed at 510 nm, and the emission is detected at 616 nm. The deconvolutions of the spectra using bi-exponential decay functions and taking into account the IRF, are plot as solid blue lines.



**Figure S9**. Time-resolved photoluminescence traces for system based on dye **P1** grafted on  $Al_2O_3$ , without (black data) and in the presence of **PCBM** (red data). The excitation is performed at 510 nm, and the emission is detected at 720 nm. The deconvolutions of the spectra using bi-exponential decay functions and taking into account the IRF, are plot as solid blue lines.